

03500.103088

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

|   |   |                                  |
|---|---|----------------------------------|
| In re Application of:                   | ) |                                  |
|   | : | Examiner: Not Yet Assigned       |
| KOHEI OKAMOTO ET AL.                    | ) |                                  |
|   | : | Group Art Unit: Not Yet Assigned |
| Application No.: Not Yet Assigned       | ) |                                  |
|   | : |                                  |
| Int'l Application No. PCT/JP2004/014809 | ) |                                  |
|   | : |                                  |
| Filed: September 30, 2004               | ) |                                  |
|   | : |                                  |
| For: PROCESS FOR PRODUCING              | ) |                                  |
| THREE-DIMENSIONAL                       | : |                                  |
| STRUCTURE                               | ) | March 23, 2006                   |

**Mail Stop PCT**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Since the U.S. Patent and Trademark Office waived the requirement under 37 C.F.R. § 1.98 (a)(2)(i) for submitting a copy of each cited U.S. patent and each U.S. patent application publication for all U.S. national patent applications and for all international applications that have entered the national stage under 35 U.S.C. § 371, no copies of such documents are enclosed. Copies of the other listed documents are enclosed.

This Information Disclosure Statement is, in part, to make of record documents cited in the International Search Report and the Written Opinion issued in the


international application of which the subject application is a national stage. Copies of the Search Report and the Written Opinion are enclosed.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

  
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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PCT/JP2004/014809  
24 MAR 2005

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| FORM PTO 1449 (modified)<br><br>U.S. DEPARTMENT OF COMMERCE<br>PATENT AND TRADEMARK OFFICE<br><br>LIST OF REFERENCES CITED BY APPLICANT(S)<br>(Use several sheets if necessary) |  |   |      | ATTY DOCKET NO.<br><b>03500.103088</b>   |       | APPLICATION NO. N.Y.A.<br><b>Nat'l Stage of<br/>PCT/JP2004/014809</b> |                                       |
|   |  |   |      | APPLICANT<br><b>Kohei Okamoto et al.</b> |       |   |                                       |
|   |  |   |      | FILING DATE<br><b>September 30, 2004</b> |       | GROUP<br><b>N.Y.A.</b>  |                                       |
| U.S. PATENT DOCUMENTS   |  |   |      |  |       |   |                                       |
| *EXAMINER<br>INITIAL  |  | DOCUMENT<br>NUMBER  | DATE | NAME                                     | CLASS | SUBCLASS  | FILING DATE<br>IF APPROPRIATE         |
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| FOREIGN PATENT DOCUMENTS  |  |   |      |  |       |   |                                       |
|   |  | DOCUMENT<br>NUMBER  | DATE | COUNTRY                                  | CLASS | SUBCLASS  | TRANSLATION<br>YES/NO/<br>OR ABSTRACT |
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|   |  |   |      |  |       |   |                                       |
| OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)  |  |   |      |  |       |   |                                       |
|   |  | <b>Xuan-Ming Duan et al., "Micron/Nanofabrication of Two and Three Dimensional Structures by Two-Photon Polymerization," Proceedings of the 2003 Third IEEE Conference on Nanotechnology, pp. 498-501 (2003).</b> |      |  |       |   |                                       |
|   |  | <b>Hong-Bun Sun et al., "Three-Dimensional Photonic Crystal Structures Achieved with Two-Photon-Absorption Photopolymerization of Resin," 74(6) Appl. Phys. Lett. 786-88 (February 1999).</b>                     |      |  |       |   |                                       |
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|   |  |   |      |  |       |   |                                       |
| EXAMINER  |  |   |      | DATE CONSIDERED                          |       |   |                                       |

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